

CHINA - CN

Jurisdiction - General Information

China has been a Contracting Party to the Paris Convention since March 19, 1985. It has also been a Contracting Party to the Patent Cooperation Treaty (PCT) since January 1, 1994. In addition, it is a party to the Budapest Treaty on the International Recognition of the Deposit of Microorganisms for the Purposes of Patent Procedure.

More legal information about intellectual property-related laws and regulations of China can be found on [WIPO Lex](#).

Online Patent Register and Online Gazette

China has an [Online Register](#) with a **Chinese (simplified) interface** and an [Online Gazette](#).

Features and search functionalities

Through the online patent register you can retrieve information on PCT **National Phase Entry, Fee Payment, Legal Status**, and access the **Full Publications**.

The patent register can also be searched by **PCT Application/Publication Number**, by **Applicant/Inventor Name**, and by **Priority Data**.

The "[China and Global Patent Examination Information Inquiry](#)" also offers an alternative source of **Legal Status** information with an interface in Chinese (simplified), **English**, French, German, Japanese, Korean, Russian and Spanish. It is also possible to find information about **Fee Payment** and to access the **Dossier/File Wrapper Information**.

Legal Status information is also available through Espacenet but with more delay (about three months).

Since June 6, 2017, the online gazette has been published twice a week on Tuesdays and Fridays in Chinese (simplified). An additional "01" or "02" is added to the Gazette's number to indicate the different publication day of the corresponding week. It is searchable by number and downloadable in PDF format. The current coverage is from 2010 to present.

Additional Information

Particularities of patent protection in China

Search tips

To search the **Online Register** for non-Chinese speakers, it is suggested to follow the [explanations in English language given by the European Patent Office](#).